

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :
Hiroto YUKAWA et al. :
Serial No. NEW : **Attn: APPLICATION BRANCH**
Filed March 29, 2004 : Attorney Docket No. 2004-0499

POSITIVE-WORKING CHEMICAL-
AMPLIFICATION PHOTORESIST
COMPOSITION

**(Rule 1.53(b) Continuation
of Serial No. 10/126,673,
Filed April 22, 2002)**

CLAIM OF PRIORITY UNDER 35 USC 119

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY
FEES FOR THIS PAPER TO DEPOSIT
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Sir:

Applicants in the above-entitled application hereby claim the date of priority under the International Convention of Japanese Patent Application No. 10-235453, filed August 21, 1998, as acknowledged in the Declaration of this application.

A certified copy of said Japanese Patent Application is of record in application Serial No. 09/376,304, filed August 18, 1999.

Respectfully submitted,

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